



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

May 19, 2026

IGI Report Number

DESCRIPTION

SHAPE AND CUTTING STYLE

MEASUREMENTS

GRADING RESULTS

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

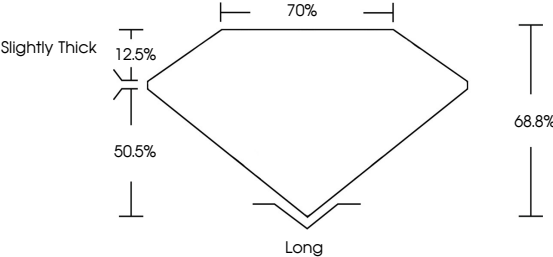
INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG801632581

Report verification at [igi.org](#)

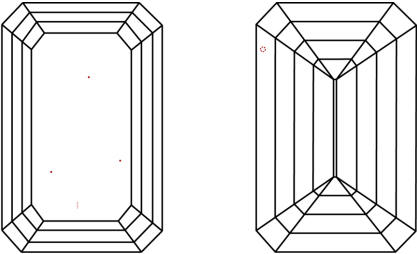
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

10.83 X 7.80 X 5.37 MM

5.00 CARATS

D

VS 1

EXCELLENT

EXCELLENT

NONE

IGI LG801632581



IGI

May 19, 2026

IGI Report No LG801632581

EMERALD CUT

10.83 X 7.80 X 5.37 MM

5.00 CARATS

D

Color Grade

VS 1

Depth

68.8%

Table

70%

Graile

Slightly Thick

Culet

Long

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

IGI LG801632581

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